## **AMENDMENTS TO THE CLAIMS**

Please amend the claims as follows:

## **Listing of Claims:**

Claim 1 (Currently Amended): An electronic device connecting method comprising: mounting an electrode of an electronic device closely on a sheet-like porous member having a hole pores, the porous member having a photosensitive layer, which produces or eliminates an ion exchange group by irradiation with energy beams[[,]] on [[a]] an inner surface in the hole of the porous member pores;

selectively irradiating a predetermined region of the porous member, on which the electronic device is mounted, with energy beams to form a latent image in an irradiated or non-irradiated portion of the porous member, the predetermined region including a portion close to the electrode;

after <u>said selectively</u> irradiating with the energy beams, filling <u>pores in the latent</u>

<u>image of the porous member with</u> a conductive material in a hole in the latent image of the

<del>porous member</del> to form a conductive portion <u>connected to the electrode</u>; and

bonding the porous member, in which the conductive portion is formed by said filling, to the electronic device.

Claim 2 (Original): An electronic device connecting method as set forth in claim 1, wherein the mounting comprises pressure sensitive adhesion.

Claim 3 (Original): An electronic device connecting method as set forth in claim 1, wherein

the photosensitive layer produces or eliminates an ion exchange group in an irradiated

or non-irradiated portion of the photosensitive layer of the porous member to form a pattern

of an ion exchange group by the energy beams, and

the conductive portion is formed by selectively absorbing a conductive material or its

precursor onto the pattern of the ion exchange group which is formed in the irradiated or non-

irradiated portion of the photosensitive layer.

Claim 4 (Original): An electronic device connecting method as set forth in claim 3,

further comprising;

electroless plating by using the conductive material or its precursor as a plating

nucleus.

Claim 5 (Original): An electronic device connecting method as set forth in claim 1,

wherein the conductive portion comprises a region which passes through the porous member,

and a region which does not pass through the porous member.

Claim 6 (Original): An electronic device connecting method as set forth in claim 1,

wherein the bonding comprises curing after a curing resin impregnates the porous member.

Claim 7-22 (Cancelled).

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